- A microelectronic device comprising: 1
- a package core having an opening therein; 2
- a microelectronic die located within the opening of said package core; and 3
- a fiber reinforced encapsulation material within the opening of said package 4
- core to hold said microelectronic die within said package core, said fiber reinforced 5
- encapsulation material including a polymeric resin having a fibrous filler material. 6
- The microelectronic device of claim 1, wherein: 2. 1
- said fibrous filler material includes individual fibers having a length between 2
- 1 micrometer and 40 micrometers. 3
- The microelectronic device of claim 1, wherein: 3. 1
- said fibrous filler material includes individual fibers having a length to width 2
- ratio that is no less than 5. 3

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- The microelectronic device of claim 1, wherein: 4. 1
- said fibrous filler material includes glass fibers. 2
- The microelectronic device of claim 1, wherein: 5. 1
- said fibrous filler material includes carbon fibers. 2
- The microelectronic device of claim 1, wherein: 6. 1
- said fibrous filler material includes Kevlar® fibers. 2
- The microelectronic device of claim 1, wherein: 7. 1
- said fibrous filler material includes ceramic fibers. 2
- The microelectronic device of claim 1, wherein: 8. 1
- said fibrous filler material includes metal fibers. 2

- 1 9. The microelectronic device of claim 1, wherein:
- 2 said polymeric resin includes epoxy.
- 1 10. The microelectronic device of claim 1, wherein:
- 2 said polymeric resin includes plastic.
- 1 11. The microelectronic device of claim 1, comprising:
- 2 at least one metallization layer built up over said package core, said at least one
- 3 metallization layer being conductively coupled to bond pads on a surface of said
- 4 microelectronic die.
- 1 12. A microelectronic device comprising:
- 2 a package substrate;
- a microelectronic die mechanically coupled to said package substrate, said
- 4 microelectronic die having a plurality of electrical contacts that are conductively
- 5 coupled to contacts on said package substrate; and
- a fiber reinforced encapsulation material mechanically coupled to said
- 7 microelectronic die to provide structural support for said microelectronic die, said fiber
- 8 reinforced encapsulation material including a polymeric resin having a fibrous filler
- 9 material.
- 1 13. The microelectronic device of claim 12, wherein:
- 2 said fiber reinforced encapsulation material forms a fillet between said
- 3 microelectronic die and said package substrate.
- 1 14. The microelectronic device of claim 12, wherein:
- 2 said fiber reinforced encapsulation material forms a globule covering said
- 3 microelectronic die.

- 1 15. The microelectronic device of claim 12, wherein:
- 2 said package substrate includes a flexible circuit board.
- 1 16. The microelectronic device of claim 15, wherein:
- 2 said fiber reinforced encapsulation material fills a region between said
- 3 microelectronic die and said flexible circuit board.
- 1 17. The microelectronic device of claim 12, wherein:
- 2 said fibrous filler material includes individual fibers having a length between
- 3 1 micrometer and 40 micrometers and a length to width ratio that is no less than 5.
- 1 18. A method for manufacturing a microelectronic device comprising:
- 2 providing a package core having an opening therein;
- positioning a microelectronic die within the opening in said package core; and
- dispensing a fiber reinforced encapsulation material into said opening in said
- 5 package core to fill a gap between said microelectronic die and said package core, said
- 6 fiber reinforced encapsulation material including a polymeric resin having a fibrous
- 7 filler material.
- 1 19. The method of claim 18, wherein:
- dispensing a fiber reinforced encapsulation material includes creating a flow of
- 3 encapsulation material about said microelectronic die in a direction that is
- 4 approximately perpendicular to a direction of anticipated crack formation.
- 1 20. The method of claim 19, wherein:
- 2 said direction of anticipated crack formation is an outward direction from a
- 3 corner of said microelectronic die.

- 1 21. The method of claim 18, wherein:
- 2 said package core includes a first channel in fluid communication with said
- 3 opening, wherein dispensing a fiber reinforced encapsulation material includes injecting
- 4 said fiber reinforced encapsulation material into said first channel.
- 1 22. The method of claim 21, wherein:
- 2 said package core includes a second channel in fluid communication with said
- 3 opening, wherein dispensing a fiber reinforced encapsulation material includes creating
- 4 a partial vacuum within said second channel.
- 1 23. The method of claim 18, comprising:
- 2 applying a first protective film over a first surface of said package core before
- 3 dispensing said fiber reinforced encapsulation material, said first protective film
- 4 covering said opening in said package core.
- 1 24. The method of claim 23, comprising:
- 2 applying a second protective film over a second surface of said package core
- 3 before dispensing said fiber reinforced encapsulation material, said second protective
- 4 film covering said opening in said package core.